

High Performance Green LEDs for Solid State Lighting

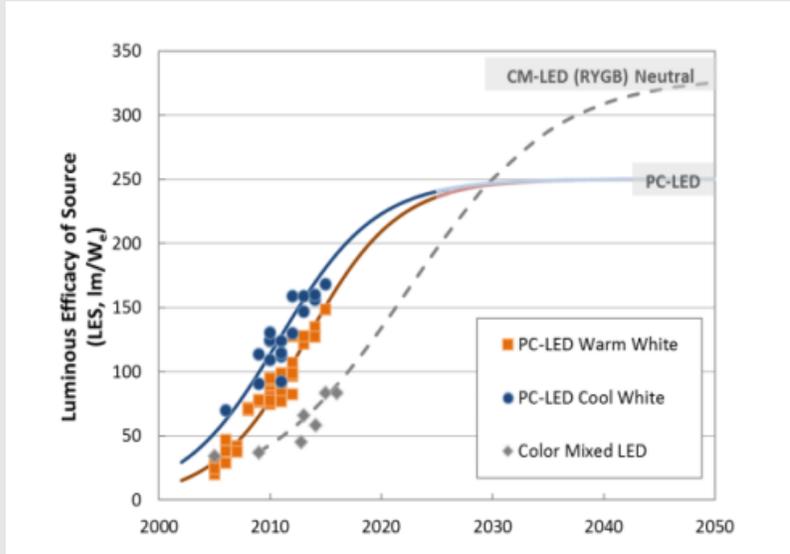
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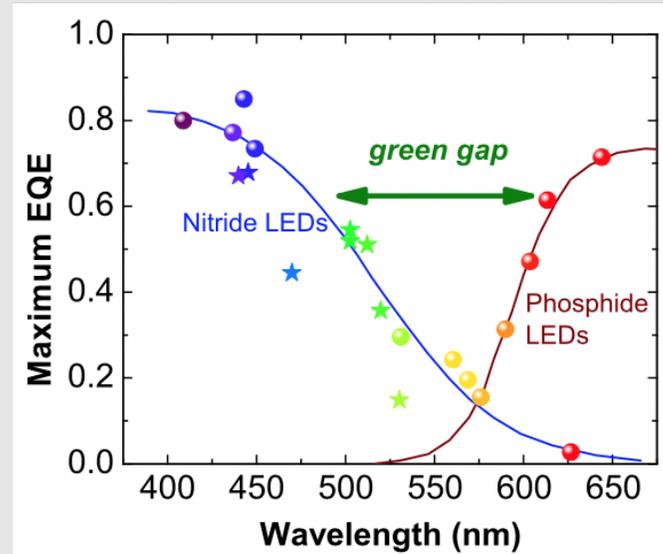
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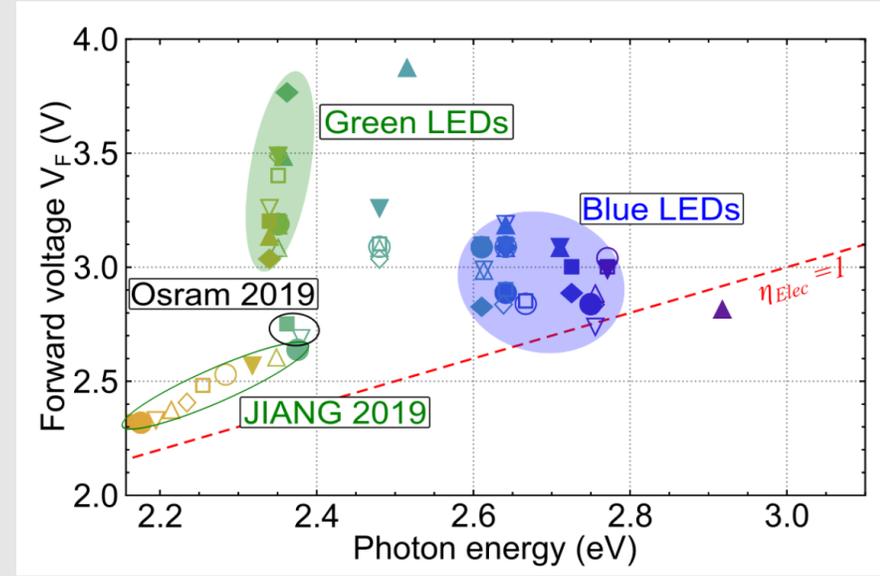
Project motivation and objectives



Color mixed LEDs using red, yellow, green, and blue LEDs, have a higher fundamental limit for luminous efficacy and better color tunability



Limitation of nitride and phosphide LEDs in green-yellow region of spectrum → “Green Gap”



$$WPE = EE \times IQE \times LEE$$

$$EE = \frac{V_{ph}}{V_F} \quad \Delta V_F = V_F - V_{ph}$$
 Large excess forward voltage ΔV_F leads to low wall plug efficiency

Solid-State Lighting 2017 Suggested Research Topics Supplement. DOE Office of Energy Efficiency & Renewable Energy September 2017.

M. Auf der Maur, *et al.*, Phys. Rev. Lett. 116, 027401 (2016).

G. Lheureux, *et al.*, J. Appl. Phys. 128, 235703 (2020).

R&D approach

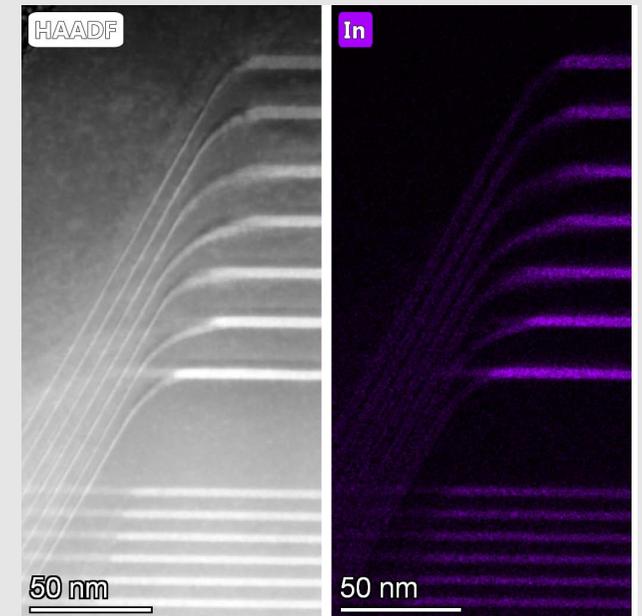
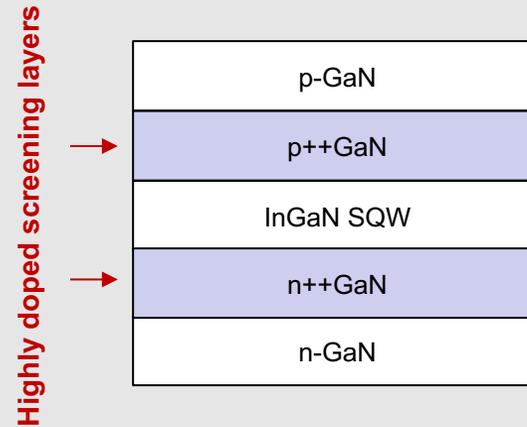
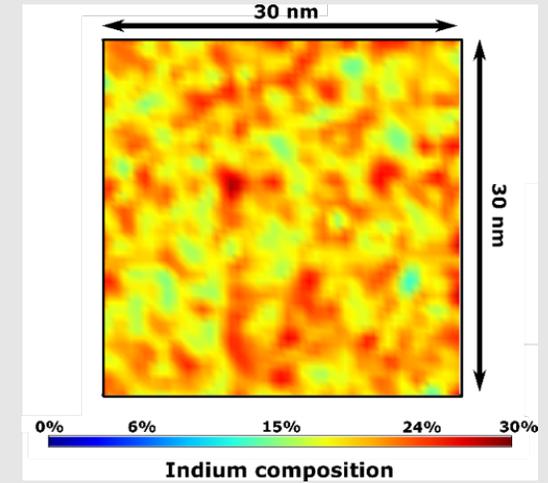
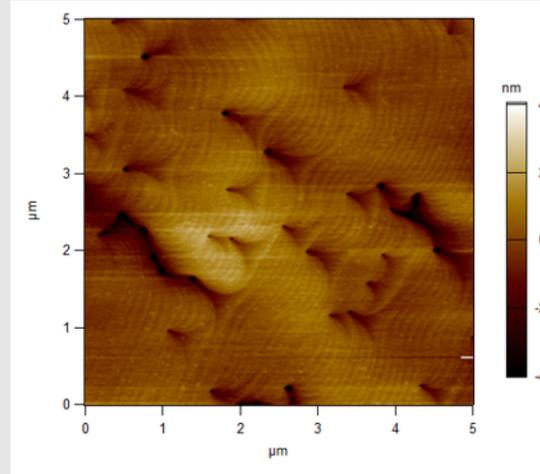
Engineering against Shockley-Read-Hall

Advanced design

Polarization engineering

Voltage reduction

Advanced characterization



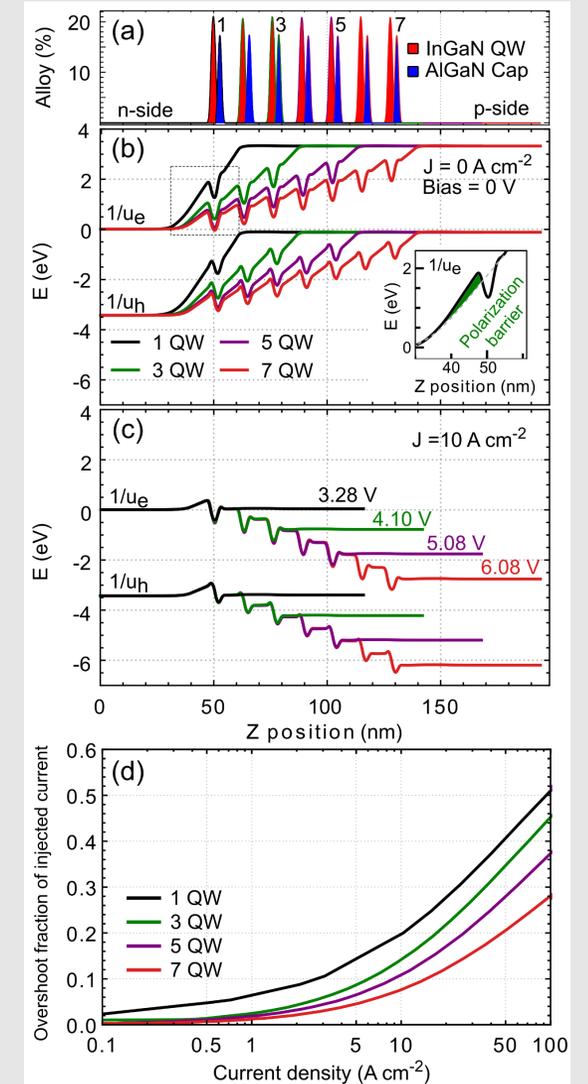
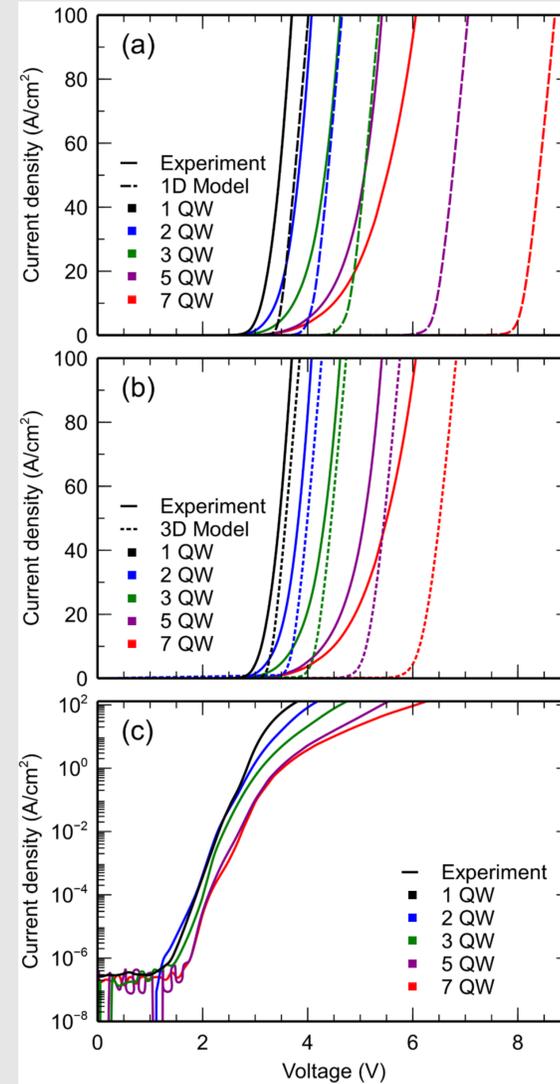
Project outcomes: origin of excess voltage in green LEDs

Green LEDs with varying QW number \rightarrow increase in V_F with each additional QW

Simulations based on landscape theory to account for alloy disorder

Agreement between experiment and 3D simulations without adjusting polarization parameters

Polarization induced barriers at the GaN/InGaN (lower barrier/QW) interfaces contribute to large ΔV_F in MQW green LEDs



C. Lynsky, *et al.*, Phys. Rev. Materials **4**, 054604 (2020).

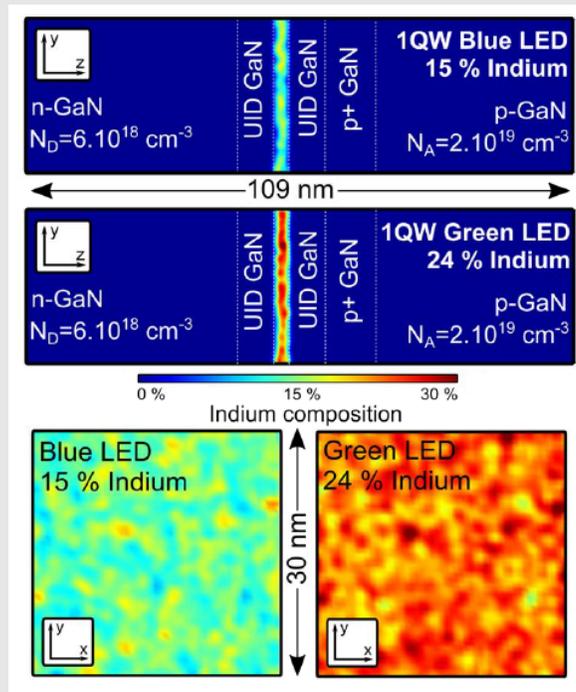
Project outcomes: origin of excess voltage in green LEDs

3D simulations based on landscape theory to account for alloy disorder

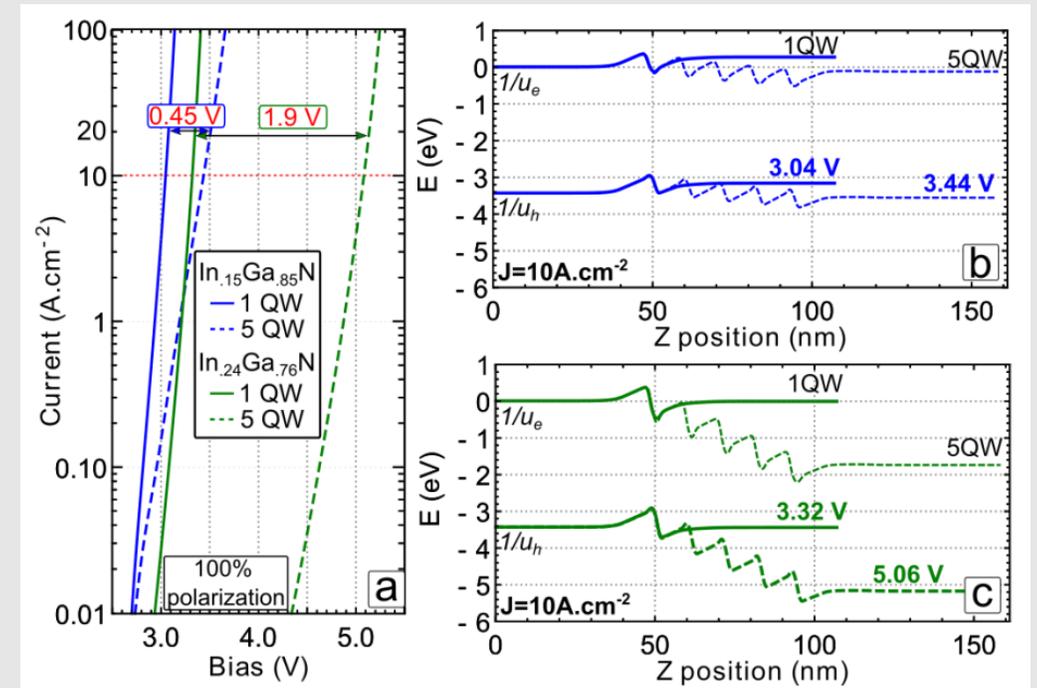
Compared blue and green LEDs with either 1 or 5 QWs

Simulated 1.9 V penalty at 10 A cm⁻² going from 1 QW to 5 QW for green LEDs

Simulated 0.45 V penalty at 10 A cm⁻² going from 1 QW to 5 QW for blue LEDs



100% Polarization



G. Lheureux, *et al.*, J. Appl. Phys. **128**, 235703 (2020).

Project outcomes: origin of excess voltage in green LEDs

Higher avg. carrier density, radiative recombination rate in top QW compared to deeper QWs

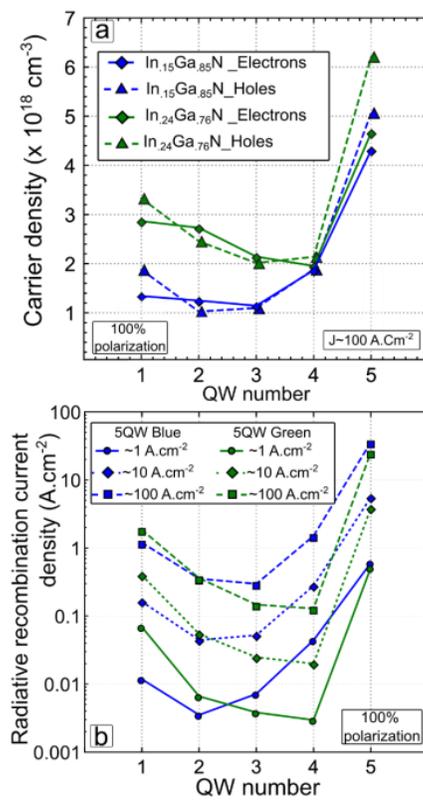
Artificially set piezoelectric and spontaneous polarization values to 0%

At 0% pol. very small penalty for blue LEDs, still large penalty for green LEDs from 1 to 5 QWs

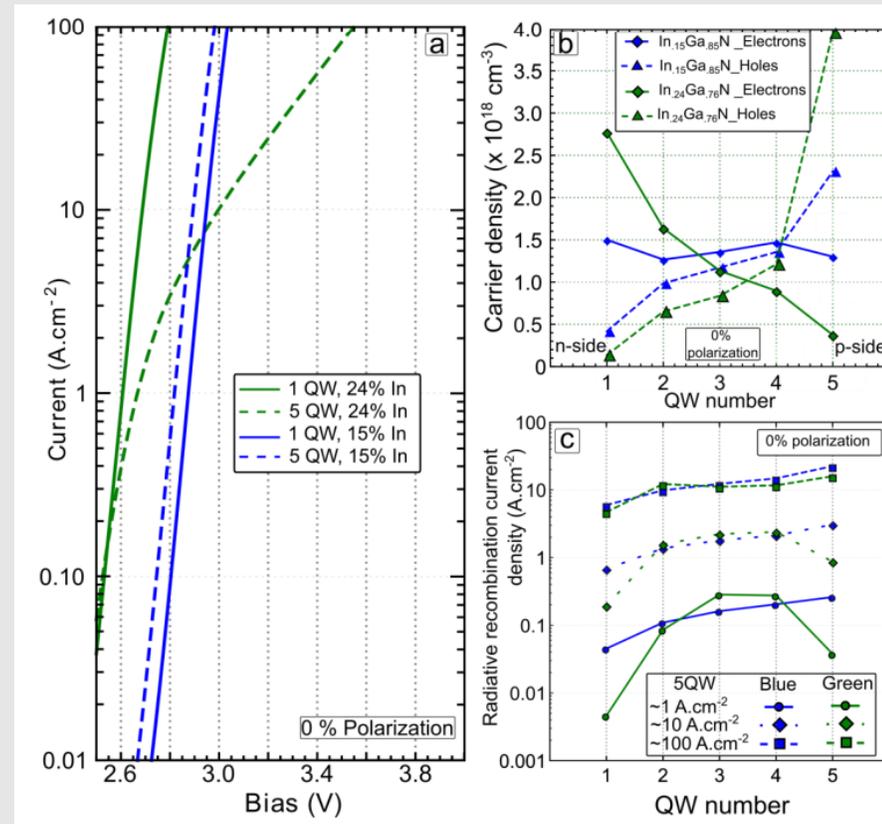
For green LED, extreme QWs have highly unbalanced carrier densities, leads to central QW having highest R_{rad} at low J

Evidence of sequential injection of carriers due to large band offsets present in green LEDs, also contributes to large ΔV_F

100% Polarization



0% Polarization

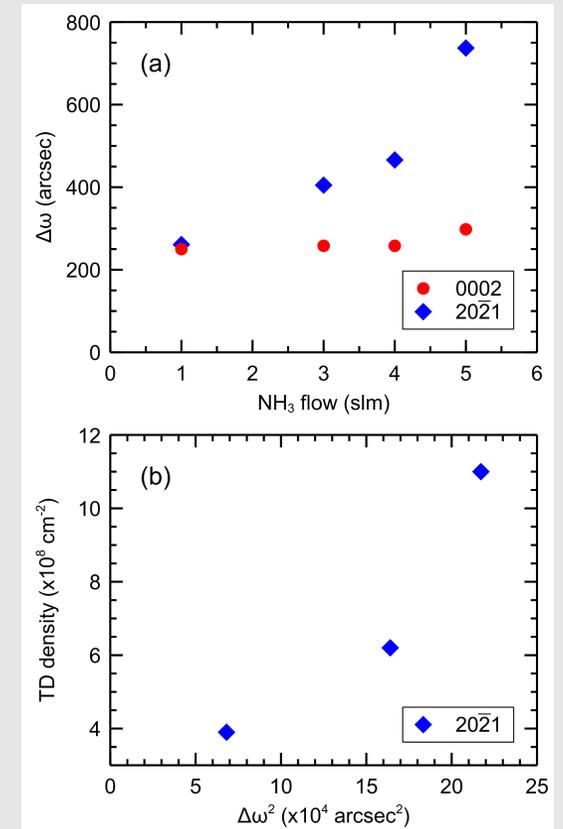
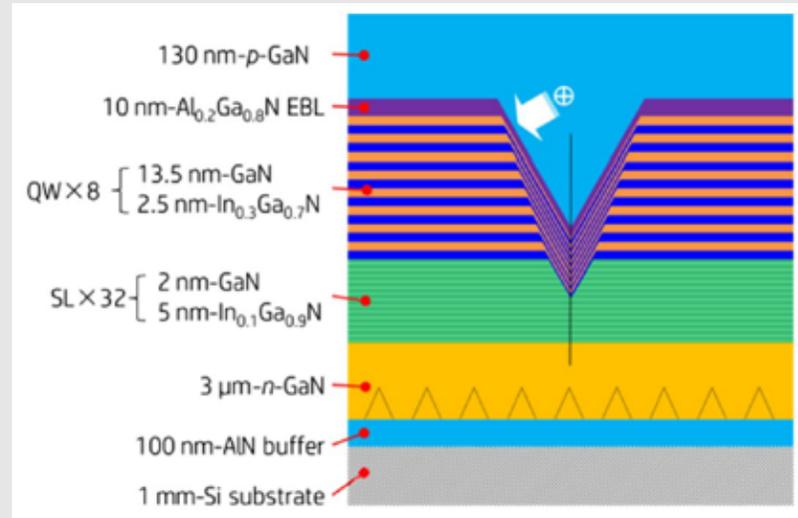
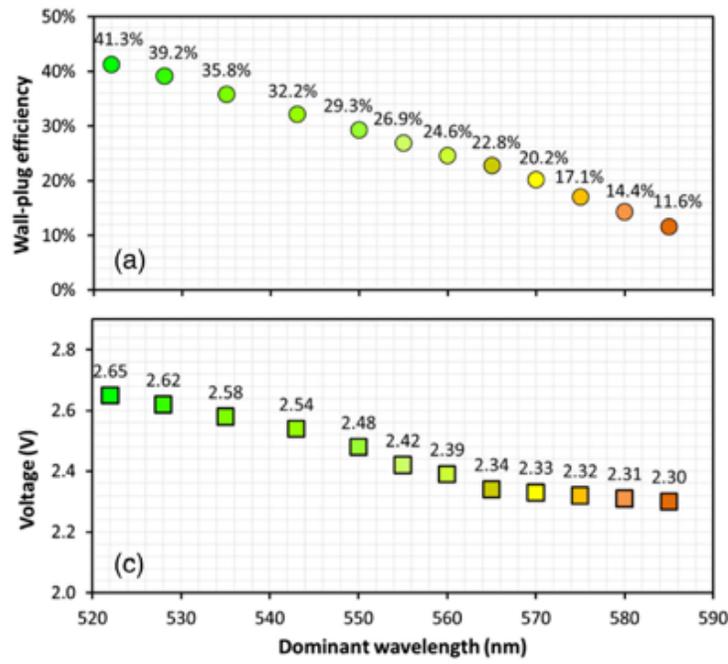


G. Lheureux, *et al.*, J. Appl. Phys. **128**, 235703 (2020).

Project outcomes: V-defect engineering

Demonstrated from 522–621 nm for GaN on Si
 Attribute low V_F to V-defects from superlattice
 Semipolar sidewall QWs \rightarrow low polarization barrier
 Improved hole injection into deeper QWs

UCSB approach: V-defect engineering on sapphire
 Difference between GaN on Si and GaN on sapphire is threading dislocation and V-defect density
Increase TD, V-defect density by increasing NH_3 flow



F. Jiang, *et al.*, Photonics Res. 7, 144 (2019).

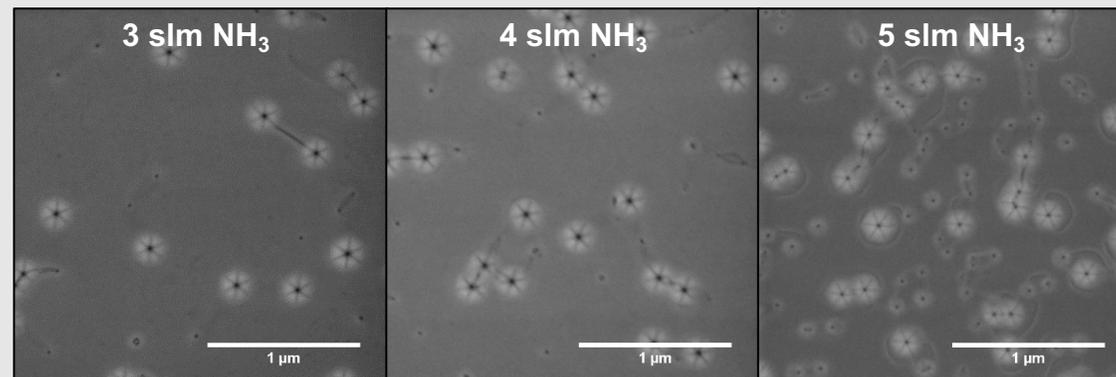
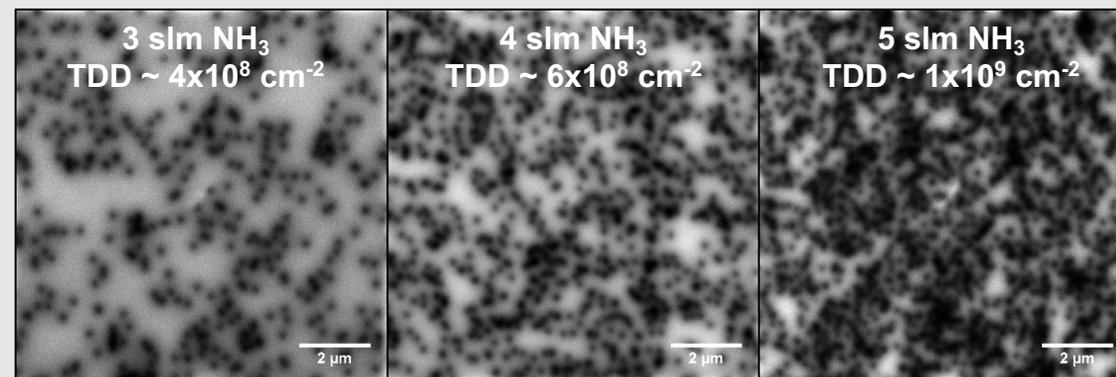
C. Lynsky, *et al.*, J. Cryst. Growth, *Accepted* (2020).

Project outcomes: V-defect engineering

| |
|--|
| 10 nm p+ GaN |
| 100 nm p-GaN, [Mg] = $5 \times 10^{19} \text{ cm}^{-3}$ |
| 10 nm p-AlGaN EBL, [Mg] = $9 \times 10^{19} \text{ cm}^{-3}$ |

Panchromatic cathodoluminescence shows increase in TDD from $\sim 4 \times 10^8$ to $\sim 1 \times 10^9 \text{ cm}^{-2}$

Interrupt growth after last QB to characterize surface



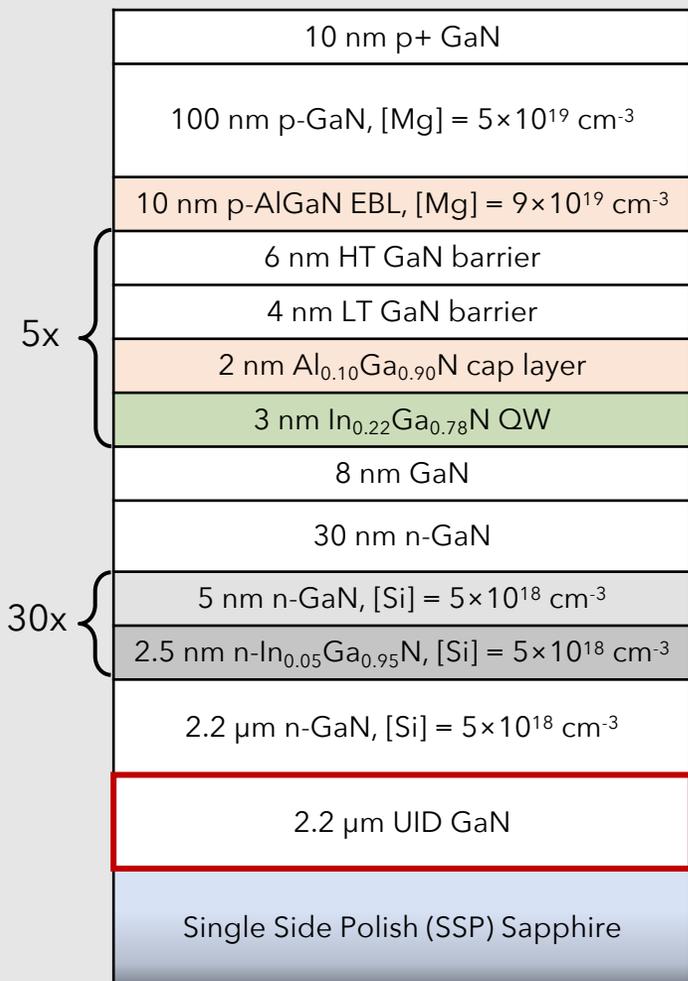
| NH ₃ flow (slm) | Avg size large defects (nm) | Density large defects (cm ⁻²) | Density small defects (cm ⁻²) | Total defect density (cm ⁻²) |
|----------------------------|-----------------------------|---|---|--|
| 3 | 184 ± 15 | 1.95×10^8 | 2.18×10^8 | 4.13×10^8 |
| 4 | 206 ± 17 | 2.64×10^8 | 3.56×10^8 | 6.19×10^8 |
| 5 | 174 ± 27 | 5.05×10^8 | 1.16×10^9 | 1.66×10^9 |

2.6x increase 5.3x increase 4x increase

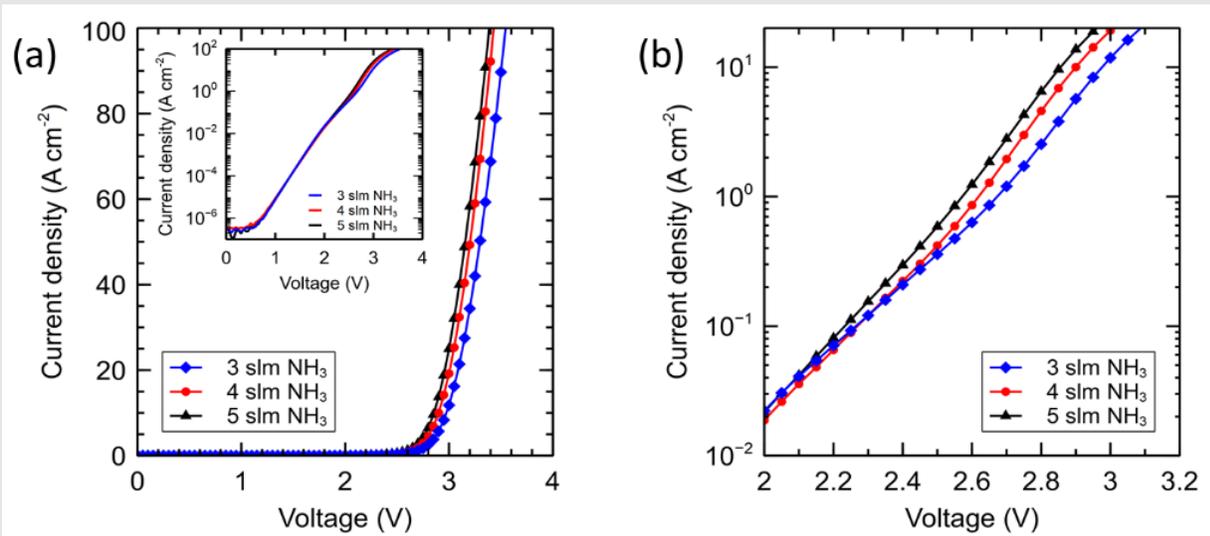
| | |
|-----|---|
| 5x | 6 nm HT GaN barrier |
| | 4 nm LT GaN barrier |
| | 2 nm Al _{0.10} Ga _{0.90} N cap layer |
| | 3 nm In _{0.22} Ga _{0.78} N QW |
| | 8 nm GaN |
| 30x | 30 nm n-GaN |
| | 5 nm n-GaN, [Si] = $5 \times 10^{18} \text{ cm}^{-3}$ |
| | 2.5 nm n-In _{0.05} Ga _{0.95} N, [Si] = $5 \times 10^{18} \text{ cm}^{-3}$ |
| | 2.2 μm n-GaN, [Si] = $5 \times 10^{18} \text{ cm}^{-3}$ |
| | 2.2 μm UID GaN |
| | Single Side Polish (SSP) Sapphire |

3 samples grown with either 3, 4, or 5 slm NH₃ flow during the temperature ramp and HT UID GaN

Project outcomes: V-defect engineering



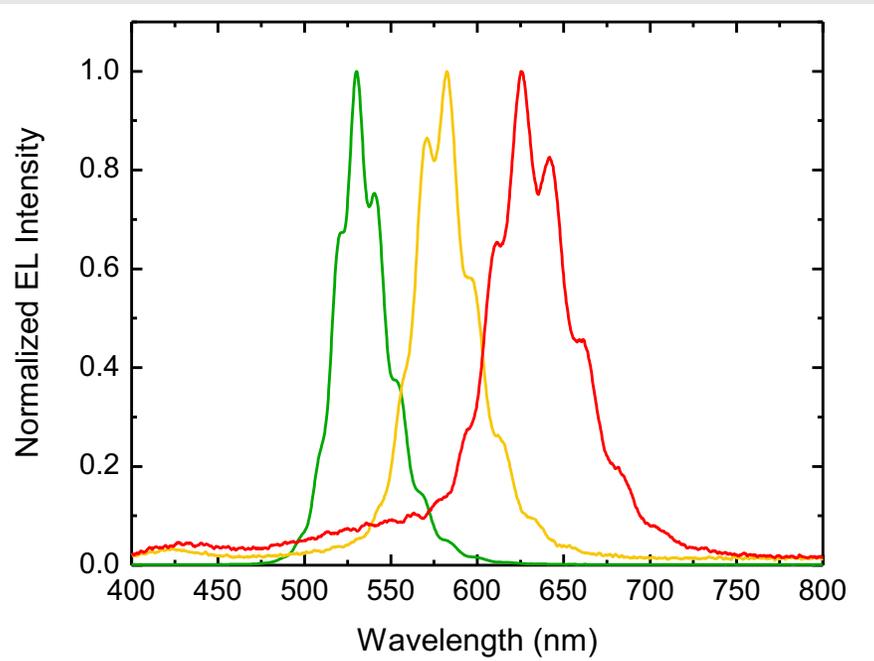
3 LEDs grown with either 3, 4, or 5 slm NH₃ flow during the temperature ramp and HT UID GaN



| NH ₃ flow (slm) | Voltage (V) | Power (mW) | Peak wavelength (nm) | FWHM (nm) |
|----------------------------|-------------|------------|----------------------|-----------|
| 3 | 3.07 | 0.53 | 516.3 | 25.9 |
| 4 | 3.02 | 0.50 | 521.1 | 28.2 |
| 5 | 2.94 | 0.43 | 522.6 | 31.8 |

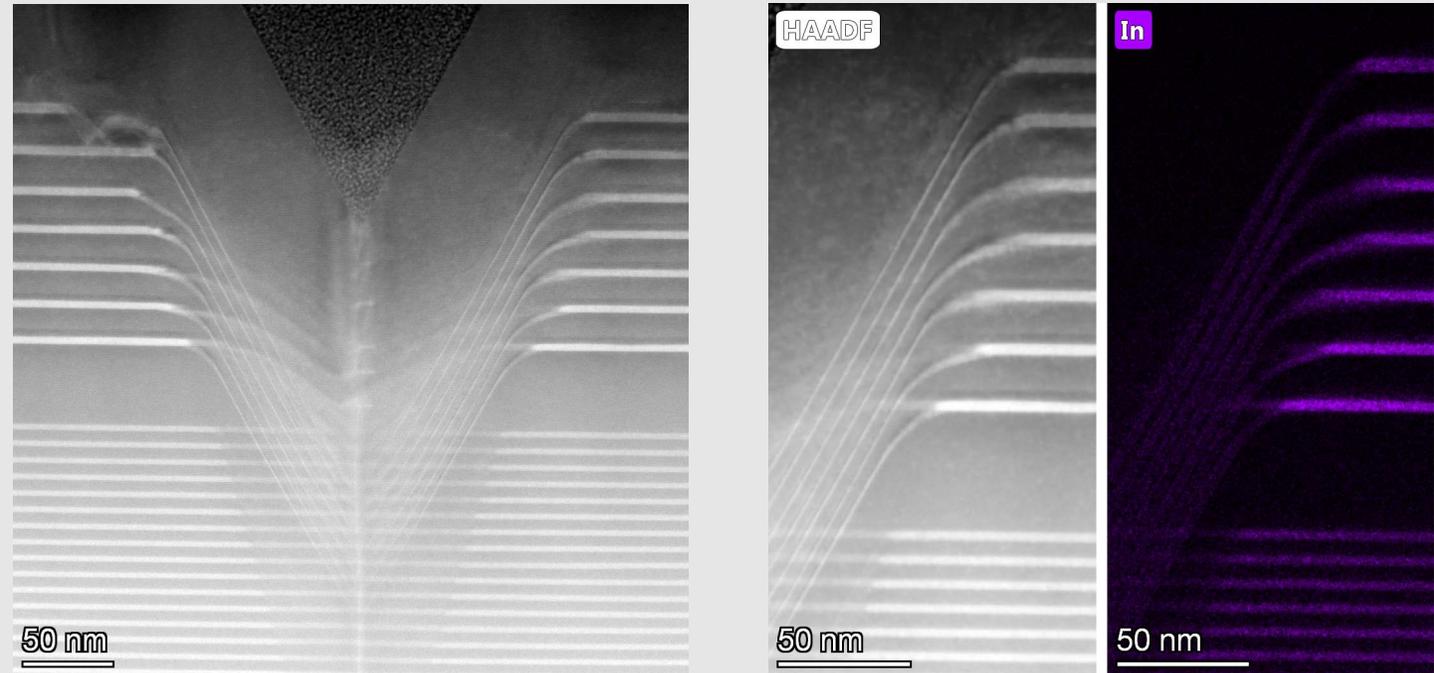
Recent and future work

Exploring V-defect engineering for long wavelength LEDs ($\lambda = 525 - 625$ nm) on sapphire and silicon substrates



Electroluminescence spectra at 5 mA of green to red LEDs grown at UCSB

Combining experimental, advanced characterization, and 3D simulations methods to realize high WPE long wavelength LEDs with reduced current droop



TEM and EDX of 7 QW red LED with engineered V-defect

Thank you